

Absolute position measurement device and measurement method

High resolution and high accuracy absolute position measurement using diffracted light

Overview

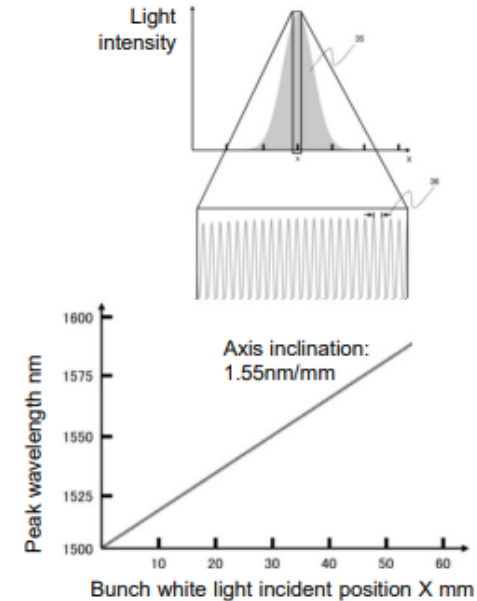
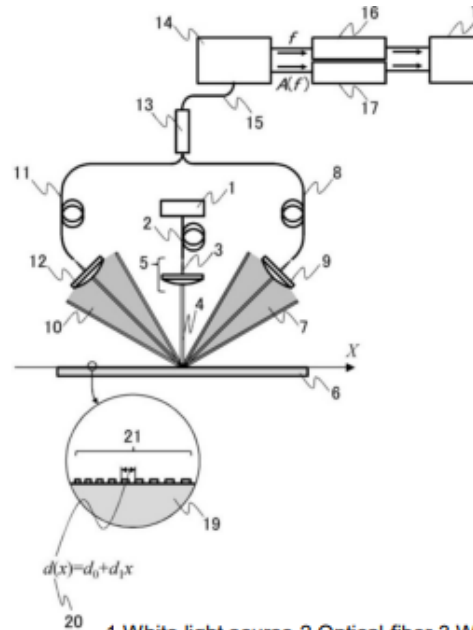
Optical linear encoder is used as high accuracy displacement sensor for semiconductor manufacturing equipment and various absolute position detection methods have been implemented. However, complex micro-pattern combinations and detection optics are necessary. For this purpose, an optical single-axis encoder that uses white light source and diffraction grating with unequal tick spacing is proposed to detect the absolute position based on the spectrum of the analyzer. However, the rotational motion error of the grating affects the position detection.

The present invention is able to provide an optical absolute position measurement device and method with high resolution and accuracy in single or double axis by analyzing the spectrum of a diffracted bunch light. An unequal spaced grating is provided to incident the bunch white light, and the absolute position is detected from the peak wavelengths detected on the optical spectrum of the analyzer.

Product Application

- ❑ High resolution & accuracy optical absolute position measurement device
- ❑ - Eliminate the effect of rotational motion error by using diffracted light
- ❑ Semiconductor manufacturing equipment
- ❑ Machine tools in factories

Features • Outstandings



1. White light source
2. Optical fiber
3. White light
4. Bunch white light
5. Bunch light generator
6. Unequal grating spacing
7. 1st order reflection diffracted bunch light
- 8/11. Optical fiber
- 9/12. Focusing lens
- 10.-1st order reflection diffracted bunch light
13. Optical coupler
14. Analyzer
15. Fiber
- 16/17/18. Signal processing
19. Diffraction grating substrate
20. Grating spacing
21. Single axis grating pattern
35. Interference signal
36. 1/2 period of grating spacing

[Up left] Schematic view of the optical system of the absolute position measurement device
[Up right] Change in optical intensity due to wavelength $\lambda(x)$ scale shift in the optical spectrum
[Down left] Transition of the peak wavelength coupled to an optical fiber at the x position of the optical system of the absolute position measuring device

IP Data

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